IN THE U.S. PATENT AND TRADEMARK OFFICE

In re application of

Hiroki SATO

Conf. 6778

Application No. 10/588,187 Group 1762

Filed August 2, 2006

ALKOXIDE COMPOUND, MATERIAL FOR THIN FILM FORMATION, AND PROCESS FOR THIN FILM FORMATION

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In compliance with Rules 1.97 and 1.98, and in fulfillment of the duty of disclosure under Rule 1.56, the cited documents are made of record on the enclosed PTO Form-1449.

As the USPTO has waived the requirement under 37 CFR 1.98(a)(2)(i) for submitting a copy of each cited U.S. patent and patent publication for applications filed after June 30, 2003, copies of the cited U.S. references are not enclosed, as the present application is filed after June 30, 2003. Copies of the cited foreign patent documents and/or non-patent literature are enclosed.

A concise explanation of the relevance of these items is that these references were cited by the Chinese Patent Office in an Official Action. A copy of the Chinese Official Action in which they were cited is attached hereto, with an English translation.

Docket No. 8007-1114 Appln. No. 10/588,187

Respectfully submitted,

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